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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/748,187	12/31/2003	Kiminori Watanabe	04329.2480-02	5539
22852 75	90 03/28/2005		EXAMINER	
FINNEGAN, HENDERSON, FARABOW, GARRETT & DUNNER			LEWIS, MONICA	
LLP 901 NEW YOR	K AVENUE, NW		ART UNIT	PAPER NUMBER
WASHINGTON	N, DC 20001-4413		2822	
			DATE MAILED: 03/28/2009	ς .

Please find below and/or attached an Office communication concerning this application or proceeding.

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		Application No.	Applicant(s)	
		10/748,187	WATANABE ET AL.	
	Office Action Summary	Examiner	Art Unit	
		Monica Lewis	2822	
Period fo	The MAILING DATE of this communicator Reply	tion appears on the cover sheet	with the correspondence addres	s
THE - External filter - If the control filter - If NO control filter - Failth Any	MORTENED STATUTORY PERIOD FOR MAILING DATE OF THIS COMMUNICATION of time may be available under the provisions of 3 of SIX (6) MONTHS from the mailing date of this communication of the period for reply specified above, the maximum statuture to reply within the set or extended period for reply will reply received by the Office later than three months after need patent term adjustment. See 37 CFR 1.704(b).	ATION. 37 CFR 1.136(a). In no event, however, may cation. 1ays, a reply within the statutory minimum of the complex of which will expire SIX (6) Months, but the complex of the complex	a reply be timely filed nirty (30) days will be considered timely. DNTHS from the mailing date of this communication ABANDONED (35 U.S.C. § 133).	nication.
Status				
1)🛛	Responsive to communication(s) filed	on 31 December 2003.		
2a)□	· · · · · · · · · · · · · · · · · · ·	☐ This action is non-final.		
3)	Since this application is in condition for	r allowance except for formal ma	atters, prosecution as to the me	rits is
	closed in accordance with the practice	under Ex parte Quayle, 1935 C	D. 11, 453 O.G. 213.	
Disposit	ion of Claims			
5)□ 6)⊠ 7)□	Claim(s) <u>6 and 19</u> is/are pending in the 4a) Of the above claim(s) is/are Claim(s) is/are allowed. Claim(s) <u>6 and 19</u> is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction	withdrawn from consideration.		
Applicat	ion Papers			
9)□ 10)⊠	The specification is objected to by the E The drawing(s) filed on 31 December 2 Applicant may not request that any objection Replacement drawing sheet(s) including the The oath or declaration is objected to be	<u>0003</u> is/are: a)⊠ accepted or b) on to the drawing(s) be held in abey e correction is required if the drawin	ance. See 37 CFR 1.85(a). ng(s) is objected to. See 37 CFR 1.	121(d).
Priority	under 35 U.S.C. § 119			
12)⊠ a)	Acknowledgment is made of a claim for All b) Some * c) None of: 1. Certified copies of the priority do 2. Certified copies of the priority do 3. Copies of the certified copies of application from the International See the attached detailed Office action for the Internation of	cuments have been received. cuments have been received in the priority documents have been large (PCT Rule 17.2(a)).	Application No. <u>09/746,223</u> . In received in this National Stag	ĵe
Attachmen	ut(s)	·		
2) 🔲 Notic 3) 🔯 Infor	ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO mation Disclosure Statement(s) (PTO-1449 or PT er No(s)/Mail Date <u>12/03</u> .	-948) Paper N	r Summary (PTO-413) o(s)/Mail Date Informal Patent Application (PTO-152))

Application/Control Number: 10/748,187

Art Unit: 2822

DETAILED ACTION

Page 2

1. This office action is in response to the preliminary amendment filed December 31, 2003.

Specification

- 2. The title of the invention is not descriptive. A new title is required that is clearly indicative of the invention to which the claims are directed.
- 3. The lengthy specification has not been checked to the extent necessary to determine the presence of all possible minor errors. Applicant's cooperation is requested in correcting any errors of which applicant may become aware in the specification.

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. Claim 6 is rejected under 35 U.S.C. 103(a) as being unpatentable over Applicant's Prior Art in view of Miyagawa (Japanese Publication No. 01-199467).

In regards to claim 6, Applicant's Prior Art discloses the following:

- a) a first-conductivity-type semiconductor layer (101) (For Example: See Figure 13B);
- b) a second-conductivity-type source region (103) formed in the semiconductor layer (For Example: See Figure 13B);
- c) a second-conductivity-type drain region (102) formed in or outside the semiconductor layer, separated from the source region (For Example: See Figure 13B);
- d) a gate electrode (105) formed above the semiconductor layer between the drain region and the source region, insulated from the semiconductor layer (For Example: See Figure 13B);

Application/Control Number: 10/748,187

Art Unit: 2822

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e) a second-conductivity-type drain contact region (106) formed in the drain region and having a higher impurity concentration than the drain region (For Example: See Figure 13B);

- f) a drain wiring (112) electrically connected to the drain region via the drain contact region (For Example: See Figure 13B);
- g) a first-conductivity-type substrate contact region (107) formed adjacent to the source region (For Example: See Figure 13B); and
- h) a source wiring (113) electrically connected to the source region, and also connected to the semiconductor layer via the substrate contact region (For Example: See Figure 13B).

In regards to claim 6, Applicant's Prior Art fails to disclose the following:

a) a distance from a contact surface of the drain wiring and the drain contact region to an edge of the source region side of the drain contact region being 5 um or more.

However, Migyagawa discloses the use a distance (L1), which is the distance from the edge of the drain region (12) facing the source region (11) and the contact hole (14), that is not less than 3 um (For Example: See Abstract) (Note: Migyagawa discloses 3 um or more which renders obvious Applicant's claimed language of 5 um or more. It appears that 3 um or more clearly encompasses 5 um or more. In the case where the claimed ranges "overlap or lie inside ranges disclosed by the prior art" a prima facie case of obviousness exists. See MPEP 2144.05). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor device of Applicant's Prior Art to include the use of a distance that is greater than 5 um as disclosed in Migyagawa because it aids in improving breakdown strength (For Example: See Abstract).

Additionally, since Applicant's Prior Art and Migyagawa are both from the same field of endeavor (semiconductors), the purpose disclosed by Migyagawa would have been recognized in the pertinent art of Applicant's Prior Art.

6. Claim 19 is rejected under 35 U.S.C. 103(a) as being unpatentable over Applicant's Prior Art in view of Miyagawa (Japanese Publication No. 01-199467) and Fujihira (U.S. Patent No. 5,736,774).

In regards to claim 19, Applicant's Prior Art fails to disclose the following:

a) a diode formed by short-circuiting the source wiring and the gate electrode.

However, Fujihira discloses the use of a diode formed by short-circuiting the source wiring and the gate electrode (For Example: See Column 12 Lines 19-21). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor device of Applicant's Prior Art to include the use of a use of a diode formed by short-circuiting the source wiring and the gate electrode as disclosed in Fujihira because it aids in reducing the voltage (For Example: See Column 12 Lines 19-21).

Additionally, since Applicant's Prior Art and Fujihira are both from the same field of endeavor (semiconductors), the purpose disclosed by Fujihira would have been recognized in the pertinent art of Applicant's Prior Art.

Conclusion

7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Monica Lewis whose telephone number is 571-272-1838.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Amir Zarabian can be reached on 571-272-1852. The fax phone number for the organization where this application or proceeding is assigned is 703-308-7722 for regular and after final

Application/Control Number: 10/748,187

Art Unit: 2822

Page 5

communications. Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956

ML

March 18, 2005

2822